Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
L1	564	438/197.ccls.	USPAT	OR	OFF	2004/11/29 06:52
L2	791	((438/199).CCLS. OR (438/229).CCLS. OR (438/232).CCLS.) not 438/197.ccls.	USPAT	OR	OFF	2004/11/29 06:53
L3	1384	((438/299).CCLS. OR (438/301).CCLS. OR (438/306).CCLS.) not 438/197.ccls.	USPAT	OR	OFF	2004/11/29 06:53
S1	522	438/197.ccls.	USPAT	OR	OFF	2004/11/29 06:51
S2	759	((438/199).CCLS. OR (438/229).CCLS. OR (438/232).CCLS.) not 438/197.ccls.	USPAT	OR	OFF	2004/11/29 06:51
S3	1348	((438/299).CCLS. OR (438/301).CCLS. OR (438/306).CCLS.) not 438/197.ccls.	USPAT	OR	OFF	2004/11/29 06:52
S4	221	438/197.ccls. and cmos	USPAT	OR	OFF	2004/09/02 20:13
S5	2501	438/197.ccls. or 438/199.ccls. or 438/229.ccls. or 438/232.ccls. or 438/299.ccls. or 438/301.ccls. or 438/306.ccls.	USPAT	OR	OFF	2004/09/02 20:14
S6	1513	(438/197.ccls. or 438/199.ccls. or 438/229.ccls. or 438/232.ccls. or 438/299.ccls. or 438/301.ccls. or 438/306.ccls.) and ((heat or heated or heats or heating or thermal or thermals) with (anneal or annealling or annealing or anneals or annealed or treatment or treatments or process or processing or processes or processed or step or steps))	USPAT	OR	OFF	2004/09/03 10:45
S7	1396	((438/197.ccls. or 438/199.ccls. or 438/229.ccls. or 438/232.ccls. or 438/299.ccls. or 438/301.ccls. or 438/306.ccls.) and ((heat or heated or heats or heating or thermal or thermals) with (anneal or annealling or annealing or anneals or annealed or treatment or treatments or process or processing or processes or processed or step or steps))) and (impurity or dope or dopants or doping or dopant or impurities)	USPAT	OR	OFF	2004/09/02 20:17

S8	841	(((438/197.ccls. or 438/199.ccls. or 438/229.ccls. or 438/232.ccls. or 438/299.ccls. or 438/301.ccls. or 438/306.ccls.) and ((heat or heated or heats or heating or thermal or thermals) with (anneal or annealling or annealing or anneals or annealed or treatment or treatments or process or processing or processes or processed or step or steps))) and (impurity or dope or dopants or doping or dopant or impurities)) and (N-type and P-type)	USPAT	OR	OFF	2004/09/02 20:17
S9	16	((((438/197.ccls. or 438/199.ccls. or 438/229.ccls. or 438/232.ccls. or 438/299.ccls. or 438/301.ccls. or 438/306.ccls.) and ((heat or heated or heats or heating or thermal or thermals) with (anneal or annealling or annealing or anneals or annealed or treatment or treatments or process or processing or processes or processed or step or steps))) and (impurity or dope or dopants or doping or dopant or impurities)) and (N-type and P-type)) and (diffusion adj furnace)	USPAT	OR	OFF	2004/09/02 20:27
S10	36	(438/197.ccls. or 438/199.ccls. or 438/229.ccls. or 438/232.ccls. or 438/299.ccls. or 438/301.ccls. or 438/306.ccls.) and (diffusion adj furnace)	USPAT	OR	OFF	2004/09/02 20:27
S11	20	((438/197.ccls. or 438/199.ccls. or 438/229.ccls. or 438/232.ccls. or 438/299.ccls. or 438/301.ccls. or 438/306.ccls.) and (diffusion adj furnace)) not (((((438/197.ccls. or 438/199.ccls. or 438/229.ccls. or 438/232.ccls. or 438/299.ccls. or 438/301.ccls. or 438/306.ccls.) and ((heat or heated or heats or heating or thermal or thermals) with (anneal or annealling or annealing or anneals or annealed or treatment or treatments or process or processing or processes or processed or step or steps))) and (impurity or dope or dopants or doping or dopant or impurities)) and (N-type and P-type)) and (diffusion adj furnace))	USPAT	OR	OFF	2004/09/02 20:27
S12	5	(("6258646") or ("6043142") or ("5563093") or ("6037201") or ("4045259")).PN.	USPAT; USOCR	OR	OFF	2004/09/03 10:45

S13	161	((((((heat or heated or heats or heating or thermal or thermals) with (anneal or annealling or annealing or anneals or annealed or treatment or treatments or process or processing or processes or processed or step or steps))) and CMOS) and (NMOS or PMOS or P-type or n-type)) and (diffusion adj furnace)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2004/09/03 10:47
S14	158	((((((heat or heated or heats or heating or thermal or thermals) with (anneal or annealling or annealing or anneals or annealed or treatment or treatments or process or processing or processes or processed or step or steps))) and CMOS) and (NMOS or PMOS or P-type or n-type)) and (diffusion adj furnace)) and silicon	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2004/09/03 10:47
S15	137	(((((((heat or heated or heats or heating or thermal or thermals) with (anneal or annealling or annealing or anneals or annealed or treatment or treatments or process or processing or processes or processed or step or steps))) and CMOS) and (NMOS or PMOS or P-type or n-type)) and (diffusion adj furnace)) and silicon) and gate	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2004/09/03 10:47
S16	134	((((((((heat or heated or heats or heating or thermal or thermals) with (anneal or annealling or annealing or anneals or annealed or treatment or treatments or process or processing or processes or processed or step or steps))) and CMOS) and (NMOS or PMOS or P-type or n-type)) and (diffusion adj furnace)) and silicon) and gate) and semiconductor	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2004/09/03 10:48